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. APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
. 10/603,929	06/26/2003	Dong Hoon Lee	8734.208.00 US	3404
30827 7590 05/11/2007 MCKENNA LONG & ALDRIDGE LLP 1900 K STREET, NW			EXAMINER	
			NGUYEN, THANH T	
WASHINGTON, DC 20006		ART UNIT	PAPER NUMBER	
			2813	
			MAIL DATE	DELIVERY MODE
			05/11/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Application No.	Applicant(s)			
		10/603,929	LEE ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Thanh T. Nguyen	2813			
Period fo	The MAILING DATE of this communication apor Reply	opears on the cover sheet with the c	orrespondence address			
THE - Exte after - If the - If NO - Failu Any	ORTENED STATUTORY PERIOD FOR REP MAILING DATE OF THIS COMMUNICATION nsions of time may be available under the provisions of 37 CFR 1 SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a re period for reply is specified above, the maximum statutory period re to reply within the set or extended period for reply will, by statute reply received by the Office later than three months after the mailined patent term adjustment. See 37 CFR 1.704(b).		nely filed  s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status		•				
1)⊠	Responsive to communication(s) filed on 27	February 2007.				
		is action is non-final.				
3)[						
Disposit	on of Claims					
5)⊠ 6)⊠ 7)□	Claim(s) 1-22 and 27 is/are pending in the ap 4a) Of the above claim(s) 1-8 is/are withdrawn Claim(s) 9-22 is/are allowed.  Claim(s) 27 is/are rejected.  Claim(s) is/are objected to.  Claim(s) are subject to restriction and/	n from consideration.				
Applicati	on Papers					
9)[	The specification is objected to by the Examin	ner.				
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
	Applicant may not request that any objection to the					
11)	Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the E					
Priority u	ınder 35 U.S.C. § 119		·			
12)⊠ a)l	Acknowledgment is made of a claim for foreig  All b) Some * c) None of:  1. Certified copies of the priority documer  2. Certified copies of the priority documer  3. Copies of the certified copies of the priority documer  application from the International Burea  see the attached detailed Office action for a lis	nts have been received.  Its have been received in Applicationity documents have been received au (PCT Rule 17.2(a)).	on No ed in this National Stage			
Attachmen	t(s)					
2)	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 r No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da  5) Notice of Informal P  6) Other:				

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### DETAILED ACTION

### Election/Restrictions

This application contains claims 1-8 drawn to an invention nonelected in the reply filed on 8/25/04. A complete reply to the final rejection must include cancellation of nonelected claims or other appropriate action (37 CFR 1.144) See MPEP § 821.01.

### Response to Arguments

Applicant's arguments filed 2/27/07 have been fully considered but they are not persuasive.

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

Claim 27 is rejected under 35 U.S.C. 102(e) as being anticipated by Ueda et al. (U.S. Patent No. 6,714,266).

Referring to figures 2a-3d, Ueda et al. teaches a method of fabricating a contact line structure for a liquid crystal display device, comprising:

forming a metal material (17, Aluminum or tungsten) on an array substrate (1);

forming a metal line (17, see figure 3c) on an array substrate by etching (patterning) the metal line (see figure 3c, col. 7, lines 11-16);

forming a silicide layer (18, see figure 3c) on the metal line direct contact (see col. 7, lines 1-20) with <u>substantially an entire surfaces</u> (top surface comprising a convex surface, concave surface, and planar surface) of the metal line (17) and the silicide layer (18) is formed in a different layer from the metal line (see figure 3c);

forming an insulating layer (9, see figure 3d) having a contact hole exposing a first portion of the silicide layer, and

forming a transparent conducting terminal (19, ITO, see figure 3D) in and on the contact hole,

wherein the insulating layer (9) is adjacent to the contact hole (see figure 3d).

# Allowable Subject Matter

Claims 9-22 are allowed. Because none of the prior art alone or in combination teaches or suggests the particular subset of the process steps in forming a silicide layer on the metal line in direct contact with upper and side surfaces of the metal line.

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# Response to Arguments

Applicant's arguments filed 2/27/07 have been fully considered but they are not persuasive.

Applicant contends that Ueda et al. does not teach forming a silcide layer on the metal line direct contact with substantially an entire surfaces. In response to applicant that Ueda et al. clearly teach forming a silicide layer (18, see figure 3c) on the metal line direct contact (see col. 7, lines 1-20) with <u>substantially an entire surfaces (top</u> surface comprising a convex surface, concave surface, and planar surface) of the metal line (17). It is also noted that <u>substantially</u> does not means that being largely but not wholly.

### Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thanh Nguyen whose telephone number is (571) 272-1695, or by Email via address Thanh.Nguyen@uspto.gov. The examiner can normally be reached on Monday-Thursday from 6:00AM to 3:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead, Jr., can be reached on (571) 272-1702. The fax phone number for this Group is (571) 273-8300.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0956 (See MPEP 203.08).

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pairdirect.uspto.gov. Should you have questions on access to thy Private PAIR system, contact the Electronic Business center (EBC) at 866-217-9197 (toll-free).

Thanh Nguyen
Patent Examiner

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Patent Examining Group 2800